Comparison: Liquids Sampling Technologies

Technology:	Sample Transfer Stripper (ASI Membrane Technologies)	Stripping Column / Sparger Flame Ionization Detector or	Gas Chromatography
	Model 204	similar	Injection valves
Principles incorporated	Henry's Law & proprietary methods	Henry's Law	Absorption
Maintenance requirements	LOW STS Membrane creates ultra-clean sample for detector & physically blocks liquids from passing through to detector. Clean only one to two times per year typical	X HIGH Plagued by frequent liquid "carry- overs". No physical block to prevent liquids from contaminating detector and gas sample lines. User reported constant cleaning & upkeep	X HIGH Column fouling common occurrence with liquid measurements. Requires high upkeep and cleaning
Moving parts	 NONE No moving parts 	X HIGH Complicated system using 85% more parts than STS Membrane	X HIGH User reported frequent fouling of chromatograph injection valves
Cost of ownership	Cost-Effective Minimal maintenance means less cost over time	X HIGH High long term cost due to constant cleaning/maintenance requirements	X HIGH High long term cost due to constant cleaning/maintenance requirements and fuel
Accuracy	 HIGH STS creates ulra-clean sample for analysis 	X LOW As system contamination occurs, accuracy drops significantly	X LOW As system contamination occurs, accuracy drops significantly
Versatility	YES STS maintains accuracy by preventing liquid carry-over. Calibrations maintains stability over long term	X NO System fouls as liquids frequently pass through to detector and gas sample lines requiring frequent cleaning	X NO Injection valves foul requiring replacement
Range	 PPB, PPM and up to 100% ranges with high precision 	X Low ppm ranges not reliable	Wide range ability but fouling reduces ability over time
Consumables	 LOW Carrier Gas/Air only. Calibrations not required. 	X HIGH Requires Carrier Gas (Nitrogen), Hydrogen fuel (for FID) and Cal Gas	X HIGH Requires Carrier Gas (Nitrogen), Hydrogen fuel (for FID) and Cal Gas
Safety	SAFE Closed loop system for analysis and cleaning. No sample exposure to user	X CAUTION User potentially exposed to residual sample when cleaning is required	X CAUTION User potentially exposed to residual sample when cleaning is required

NOTE: Data listed is typical and may vary based on manufacturer.